WHAT IS CLAIMED IS:

- 1. An industrial process diagnostic apparatus for identifying a root cause of an aberration in an industrial process, comprising:
 - a plurality of process models, each model
 related to a physical implementation of an
 industrial process;
 - a model selection input configured to receive a selected model, the selected model uniquely identifying one of the process models;
 - a process signal input configured to receive a plurality of process signals related to the process; and
 - a root cause output indicative of a source of the aberration in the process, the root cause output a function of the selected model and the process signals.
- 2. The apparatus of claim 1 including a model options input configured to receive model options related to devices which are optional in the selected model, and wherein the root cause output is further a function of the model options.
- 3. The apparatus of claim 2 wherein the model options comprise process signals.
- 4. The apparatus of claim 1 wherein each model includes a rule base.

- 5. The apparatus of claim 4 wherein the rule base provides a relationship between the process signals and a root cause of an aberration in the process.
- 6. The apparatus of claim 4 wherein each model includes a plurality of rule bases, each rule base related to the number of process signals.
- 7. The apparatus of claim 1 wherein the apparatus is implemented in a PC.
- 8. The apparatus of claim 1 wherein the apparatus is implemented in a process device.
- 9. The apparatus of claim 8 wherein the process device comprises a transmitter.
- 10. The apparatus of claim 8 wherein the process device comprises a controller.
- 11. The apparatus of claim 1 wherein the model includes a graphical model which provides a graphical representation of the physical implementation of the process.
- 12. The apparatus of claim 1 wherein the plurality of process signals comprise a primary process

variable (PV), a control demand (CD) signal, and a setpoint (SP).

- 13. The apparatus of claim 12 wherein the plurality of process signals further includes a process signal indicative of an actual control value provided in response to the control demand (CD).
- 12. The apparatus of claim 10 wherein the plurality of process signals further includes a redundant primary process variable (PV).
- 13. The apparatus of claim 1 wherein at least one of the plurality of process models is representative of a liquid level process control loop.
- 14. The apparatus of claim 1 wherein at least one of the plurality of process models is representative of a process fluid flow control loop.
- 15. A diagnostic method in an industrial process for identifying a root cause of an aberration in an industrial process, comprising:
 - selecting a process mode from a plurality of process models, each model related to a physical implementation of an industrial process, the selected model uniquely identifying one of the process models;

- receiving a plurality of process signals related to the process; and
- identifying a root cause indicative of a source of the aberration in the process, the identifying as a function of the selected model and the process signals.
- 16. The method of claim 15 including receiving model options related to devices which are optional in the selected model, and wherein identifying the root cause is further a function of the model options.
- 17. The method of claim 16 wherein the model options comprise process signals.
- 18. The method of claim 15 wherein each model includes a rule base.
- 19. The method of claim 18 wherein the rule base provides a relationship between the process signals and a root cause of an aberration in the process.
- 20. The method of claim 18 wherein each model includes a plurality of rule bases, each rule base related to the number of process signals.
- 21. A PC implementing the method of claim 15.

- 22. A process device implementing the method of claim 15.
- 23. The method of claim 15 wherein the model includes a graphical model and the method including displaying a graphical representation of the physical implementation of the process.
- 24. The method of claim 15 wherein the plurality of process signals comprise a primary process variable (PV), a control demand (CD) signal, and a setpoint (SP).
- 25. The method of claim 24 wherein the plurality of process signals further includes a process signal indicative of an actual control value provided in response to the control demand (CD).
- 26. The method of claim 24 wherein the plurality of process signals further includes a redundant primary process variable (PV).
- 27. The method of claim 15 wherein at least one of the plurality of process models is representative of a liquid level process control loop.
- 28. The method of claim 15 wherein at least one of the plurality of process models is representative of a process fluid flow control loop.

- 29. A storage medium containing computer instructions configured to implement the method of claim 1.
- 30. An industrial process diagnostic apparatus for identifying a root cause of an aberration in an industrial process, comprising:
 - means for storing a plurality of process models,
 each model related to a physical
 implementation of an industrial process;
 - means for receiving a model selection input
 uniquely identifying one of the process
 models;
 - means for receiving a plurality of process signals related to the process; and
 - means for identifying a root cause indicative of a source of the aberration in the process as a function of the selected model and the process signals.